HB

	Application No.	Applicant(s)	
Notice of Allowability	10/827,144	TAKASU ET AL.	
	Examiner	Art Unit	
	Dalei Dong	2879	_
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED) or other appropriate comm IGHTS. This application is	in this application. If not included nunication will be mailed in due course. I	
1. 🔀 This communication is responsive to Request for Continue	ed Examination filed on Apr	il 4, 2006.	
2. The allowed claim(s) is/are <u>1-22</u> .			
 3. Acknowledgment is made of a claim for foreign priority unerstanding a) All b) Some* c) None of the: . 1. Certified copies of the priority documents have 		or (f).	
2. Certified copies of the priority documents have	, ,		
3. Copies of the certified copies of the priority do	cuments have been receive	ed in this national stage application from	the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requiremen	ts
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give)F
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) I including changes required by the Notice of Draftspers	son's Patent Drawing Revie	w (PTO-948) attached	
1) ☐ hereto or 2) ☐ to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner' Paper No./Mail Date	s Amendment / Comment o	or in the Office action of	,
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t			
6. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT	SIT OF BIOLOGICAL MAT FOR THE DEPOSIT OF B	ERIAL must be submitted. Note the OLOGICAL MATERIAL.	
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Attachment(s)	5 □ Nadian at		
1. Notice of References Cited (PTO-892)		nformal Patent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	o. [_] interview of Paper No	Summary (PTO-413), ./Mail Date	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0	08), 7. ☐ Examiner'	s Amendment/Comment	
Paper No./Mail Date 4.	8. K Examiner'	s Statement of Reasons for Allowance	
	9. 🗌 Other		
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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on April 4, 2006 has been entered.

Allowable Subject Matter

- 2. Claims 1-22 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

Regarding to independent claim 1, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent device comprising the electroluminescent layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 3 and 13, are allowable because of dependency upon the allowable independent claim 1.

Regarding to independent claim 2, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent device comprising the electroluminescent layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 4 and 14, are allowable because of dependency upon the allowable independent claim 2.

Regarding to independent claim 5, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent device comprising the first electroluminescent layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 9 and 15, are allowable because of dependency upon the allowable independent claim 5.

Regarding to independent claim 6, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent device comprising the first electroluminescent layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 10 and 16, are allowable because of dependency upon the allowable independent claim 6.

Regarding to independent claim 7, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent device comprising the hole injecting layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 11 and 17, are allowable because of dependency upon the allowable independent claim 7.

Regarding to independent claim 8, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing an electroluminescent

device comprising the hole injecting layer is formed using an electrochemical method by flowing a current to one of the pair of electrodes with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 12 and 18, are allowable because of dependency upon the allowable independent claim 8.

Regarding to independent claim 19, prior art of record taken alone or in combination fails to teach or suggest a method for manufacturing a semiconductor device comprising forming organic layer using electrochemical method by flowing a current to the electrode with a current density from 0.4 to 1.5 mA/cm² for 0.8 to 3.0 seconds and in combination with other claimed features of the present invention.

Regarding to claims 20-22, are allowable because of dependency upon the allowable independent claim 19.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Dalei Dong whose telephone number is (571)272-2370. The

examiner can normally be reached on 8 A.M. to 5 P.M..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Nimeshkumar Patel can be reached on (571)272-2457. The fax phone number for the

organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

D.D.

June 1, 2006

Karabi Guharay Primary Examiner

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